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[10191/3939]

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s) : Andrea URBAN et al.
Serial No. : 10/520,886
Filed : July 21, 2005
For : **A LAYER SYSTEM COMPRISING A SILICON LAYER
AND A PASSIVATING LAYER, A METHOD FOR
PRODUCING A PASSIVATING LAYER ON A
SILICON LAYER AND THEIR USE**

Examiner : Laura M. SCHILLINGER
Art Unit : 2813

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT

SIR:

In the Office Action dated October 9, 2007, the Examiner required restriction to one of the following inventions.

Group I - claims 13-28
Group II - claims 29 and 30

Accordingly, applicants hereby elect, without traverse, the claims of Group I, i.e., claims 13-28.

An early and favorable action on the merits is earnestly solicited.

No fee is believed to be required. However, if any fee is required, please charge to Deposit Account No. 11-0600. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

KENYON & KENYON LLP

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to:
Mail Stop Amendment
Commissioner for Patents, P.O. Box 1450, Alexandria, VA. 22313-1450
on

Date: 11/2/07

Signature: [Signature]
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